CWM Metadata Interchange Patterns Specification

OMG Formal Specification March 2004 formal/04-03-25



OBJECT MANAGEMENT GROUP

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Preface

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The type styles shown below are used in this document to distinguish programming statements from ordinary English. However, these conventions are not used in tables or section headings where no distinction is necessary.

Helvetica bold - OMG Interface Definition Language (OMG IDL) and syntax elements.

Courier bold - Programming language elements.

Helvetica - Exceptions

Acknowledgments

The following companies submitted and/or supported the CWM Metadata Interchange Patterns specification:

- Hyperion Solutions Corporation
- IBM Corporation
- Oracle Corporation
- Unisys Corporation

Introduction

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1.1 Purpose

The purpose of the Common Warehouse Metamodel specification is to define a common interchange specification for metadata in a data warehouse. This definition provides a common language and metamodel definitions for the objects in the data warehouse. CWM describes a format to interchange metadata, but lacks the knowledge to describe any particular type of interchange. The need to define the context of a CWM interchange was discovered when the CWM co-submitting companies produced the CWM Interoperability Showcase. In order to make an effective demonstration of CWM technology, the participants needed to agree upon the set of metadata to be interchanged.

The purpose of this specification (CWM Metadata Interchange Patterns, or CWM MIP) is to add a semantic context to the interchange of metadata in terms of recognized sets of objects or object patterns. We will introduce the term "Unit of Interchange" (UOI) to define a valid, recognizable CWM interchange. From this information, a user of CWM, working in conjunction with CWM MIP, should be able to produce truly interoperable tools.

CWM MIP augments the current CWM metamodel definitions by adding a new metamodel package. This new metamodel will provide the structural framework to identify both a UOI and an associated model of a pattern, and providing the necessary object definitions to describe both.

1.2 Design Rationale

1.2.1 Design Overview

The goal of this specification is to leverage the existing CWM as much as possible. This specification extends CWM and conforms to the design rationale as outlined in the CWM specification, Design Rationale section.

1.2.2 The Relationship between CWM MIP and CWM

CWM has been adopted as OMG's standard for representing data warehouse metadata. The CWM MIP metamodel extends the CWM standard without altering any existing CWM implementations. This allows users of CWM MIP to use the data warehouse models defined by CWM and add the semantics of how to produce a UOI without an intrusion into the CWM definition.

CWMMIP Specification

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2.1 Introduction

The CWM metamodels contain a robust common object definition of concepts found in many datawarehouse tools. These common object definitions can be interchanged between tools to provide some level of interoperability. Through the production of the CWM Interoperability Showcase the CWM Team discovered that without some prior knowledge as to how the interchange document was produced seamless interoperability between the respective tools was not achieved. The key piece of information that was missing was what was the context of the interchange. In general, the entire document needed to be read and processed before the tool could then try to determine if this interchange was possible.

CWM covers a large number of subject areas in the datawarehouse space. It is unlikely that any individual tool will cover the entire CWM model. By identifying and cataloging inter-related concepts that can be interchanged together, tools can code for smaller domain specific portions of CWM. We call the identification of these inter-related CWM concepts *CWM metadata interchange patterns*.

2.2 Applying Pattern Concepts to the Metadata Interchange Problem

<u>Definition</u>: A *Software Design Pattern* is a description of communicating objects and classes that are customized to solve a general design problem within a particular context (Gamma et al, 1995).

The traditional "gang of four (GOF)" design patterns helped to standardize the usage of object-oriented software and components in solving typical, recurring, programming problems. Software design patterns may be formally modeled in the UML by providing generic class models along with associated, sample collaborations; i.e., *parameterized collaborations* (see Rumbaugh et all, 1999, pp. 387-388, Booch et al, 1999, pp. 381-392, and Sunye et al, 2000).

The formalization of Metadata Interchange Patterns, as put forth in this specification, is highly analogous to software design patterns, borrowing GOF terminology and introducing metadata structuring concepts that have direct analogues in the software patterns world.

<u>Definition</u>: A *CWM Metadata Interchange Pattern* is an identified subset of the CWM metamodel, optionally with constraints on the instances of the metamodel subset.

The subset traverses one or more CWM metamodels, and defines the *metamodel subspace* of the solution. The constraints (if defined) establish *boundaries* on the solution subspace. Note that these constraints are components of the pattern itself, and are not to be confused with the constraints defined by the CWM metamodel proper.

Defining metadata intechange patterns in this manner is done for two purposes:

- 1. By defining these patterns, we constrain the universe of all possible combinations of instances of CWM model elements (which is countably infinite set, by virture of the fact that there are many unbounded association ends used throughout the metamodel).
- 2. This constrained set of metadata patterns should also generally reflect the more common metadata interactions that take place within the data warehousing and business intelligence/analysis domains. Thus, we are not only attempting to overcome combinatorial explosions by restricting the model search space in some formal manner, but we are also ensuring that this restricting subspace contains elements that are semantically meaningful to the application domain.

The main benefit provided by metadata interchange patterns, of course, is that they greatly enhance interchange and interoperability by enabling software tools to focus on only those metadata patterns that are meaningful to what a given tool expects from the

metadata it imports. This greatly increases the probability that metadata interchange attempts occuring within a particular DW/BI context will be successful. It also greatly simplifies tool design.

Note that the metadata interchange solution specification, as described above, is totally non-intrusive to CWM; it consists only of identifying and constraining subsets of the CWM metamodel. It does not require any modification of the CWM metamodel.

2.3 The CWM MIP Model

The CWM metadata interchange pattern approach described previously may be realized though the use of another metamodel that (non-intrusively) extends certain CWM model elements, but is otherwise "parallel" to the rest of the CWM model structure.

To formally model a CWM interchange pattern specification, first note that the identification of inter-related concepts in CWM (i.e., the *solution subspace*) is really the identification of inter-related CWM packages and their contents. The new metamodel must allow users to catalog the characteristics of the types of units of interchange they intend to produce. This model must also capture several key details about how the interchange will be performed. The CWM MIP Model is the proposed, formal model of a CWM metadata interchange pattern, and is illustrated in Figure 2-1.

Note that the CWM MIP Model, as a formalization of a CWM metadata interchange pattern, is roughly equivalent to the specification of a *parameterized collaboration* in the UML modeling of GOF-style software design patterns, and the CWM Metamodel itself is analogous to the class diagrams that are generally used in defining the domains of GOF-style patterns.



Figure 2-1 CWM MIP Model: Main classes

There are two primary classes: *UnitOfInterchange*, a subclass of CWM *Namespace* that contains the complete CWM instance (model/metadata) being interchanged, and *InterchangePattern*, which formally describes the pattern that the content of UnitOfInterchange conforms to.

InterchangePattern also contains a reflexive association to model pattern composition, in which patterns are comprised from other pattern definitions. The attributes of InterchangePattern are as follows:

Name: The name of the interchange pattern.

Version: The version of the interchange pattern.

URI: A URI identifying a human-readable pattern specification document that describes the interchange pattern.

Classification: The structural classification of the pattern: Micro Pattern, Domain Pattern, Macro Pattern (these are defined in Section 2.6, "Pattern Specification and Cataloging," on page 2-10).

Category: The usage category of the pattern: Interchange, Mapping, Typing, Extension, Interpretation, Generation, Structural (these are defined in Section 2.6, "Pattern Specification and Cataloging," on page 2-10).

Projection: An object-valued array of type Projection (see the definition of the Projection class below) that stores the metamodel graph subset defining the semantic context of the pattern. If this attribute contains more than one value, then the complete projection of the pattern is the graph union of multiple projection object values. This attribute has a multiplicity of 1..*.

/ComponentPattern: A reference to the collection of component patterns that this pattern is comprised of (if any). This reference is a derived attribute based on the componentPattern end of the reflexive association.

Figure 2-2 shows the remaining classes of the model. Note that these classes are used exclusively to define the types of certain object-valued attributes in other parts of the model.



Figure 2-2 CWM MIP Model: Types

PatternConstraint is used to define constraints against the metamodel Projection (described below). There is no requirement to use any particular constraint language. However, if OCL is used, the OCL expression contained by PatternConstraint must be a valid OCL expression relative to the modeling context of the Projection.

Projection is an abstract base class that models the semantic context of the pattern, where by semantic context we mean a well-defined subset of the CWM metamodel graph. Projection has two concrete subclasses: *SemanticContext* and *GraphSubset*. SemanticContext specifies a projection by explicitly enumerating the CWM model elements and associations comprising the projection, along with any constraints on those elements. Note that this is the formal projection model as described in Section 2.6, "Pattern Specification and Cataloging," on page 2-10).

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GraphSubset, on the other hand, allows the projection to be specified by an expression which, when evaluated, describes some physical sub-graph of the CWM UML model.

In very general terms, SemanticContext allows for a very finely grained, but explicitly enumerated, projection, whereas GraphSubset allows for a course-grained, but more efficiently specified, projection.

The attributes of the SemanticContext class are as follows:

Element: Names of the CWM metamodel classes comprising the projection, based on logical names expressed as strings. This attribute has a multiplicity of 0..*. These logical names may refer to elements from multiple CWM metamodel packages. For example, a value for this attribute might consist of the following collection of the strings:

"org.omg.cwm.analysis.olap.Dimension"

"org.omg.cwm.objectmodel.core.Attribute"

Association: Names of the CWM associations comprising the projection, based on logical names expressed as strings. This attribute has a multiplicity of 0..*. These logical names may refer to associations from any number of CWM packages, including associations that span packages. For example, a value for this attribute might consist of the string:

"org.omg.cwm.objectmodel.core.ClassifierFeature"

Constraint: A collection of pattern constraints that apply to the elements and associations comprising the projection. This attribute has a multiplicity of 0..*. For example, a value for this attribute might consist of the OCL expression:

"context Dimension inv: self.feature->size => 1 and self.feature->exists(f | f.oclType(Attribute) and f.oclAsType(Attribute).ModelElement::name = "key")->size = 1"

There are two kinds of constraints that might be applied against the projection: *Restrictions* and *Binding Parameters* (or simply *Parameters*). In general, a restriction imposes structural constraints on an instance of a projection (e.g., by forcing an upper bound on an otherwise unbounded association end). The resulting structure is then regarded as being invariant with regard to other values that might be supplied in the construction of a pattern instance (e.g., values of certain class attributes). An example of a restriction on structure is the requirement stated above that every instance of Dimension must have at least one related Attribute. Parameters, on the other hand, typically assert values (or value ranges) for class attributes. Parameters do not influence structure, but influence content instead.

An example of a parameter is the requirement stated above that precisely one of a Dimension's Attributes must carry a name value of "key." A given pattern definition does not necessarily have to specify value constraints for all class attributes, in which case, those class attributes are said to be free. It is up to the process constructing the pattern instance to decide what values to populate free class attributes with (or to not supply any values). Note that a parameter might also specify that some class attribute must not be without a value (e.g., must be non-blank or non-zero) without specifying precisely what that value is to be.

In many cases, distinctions between restrictions and parameters may sometimes become somewhat blurred. In order to differentiate between the two types of constraint when necessary, the model supplies two subclasses for PatternConstraint: Restriction and BindingParameter. These subclasses are provided for naming/typing purposes only. A pattern definition may choose to distinguish between either type of constraint, or may choose to simply blend constraints together by using the PatternConstraint superclass rather than either of the two subclasses.

One of the main reasons why one might use the Restriction and BindingParameter subclasses is to provide a trace-back to the non-model-based pattern specification template prescribed by the CWM Developer's Guide (John Wiley & Sons, 2002). This template differentiates between restrictions and parameters as part of the pattern formulation process.

AnchorElement: Names CWM metamodel elements from the projection that have some distinguished meaning. Generally, these elements are thought of as root objects of the metamodel projection graph and are used as starting points for navigating the graph. This attribute has a multiplicity of 0..*. Although a projection may have multiple anchor elements, in practice, most projections will usually have a single anchor point. For example, a value for this attribute might consist of the string:

"org.omg.cwm.analysis.olap.Dimension"

The attributes of the GraphSubset class are as follows:

Element: The logical name of a CWM metamodel element (usually a package or class) comprising the physical projection For example, a value for this attribute might consist of the following string:

"org.omg.cwm.resource.relational.Schema"

DeepCopy: A Boolean attribute which, when true, implies that all connected elements and their attributes, within the boundaries of the specified package, are to be included in the pattern projection.

CopyDepth: An integer value that specifies the number of graph edges to traverse when establishing the physical graph projection, in cases when deepCopy is false.

AggregationsOnly: A Boolean attribute which, when true, specifies that only composite elements and their components are to be included in the physical graph projection.

IncludeAssociations: A Boolean attribute which, when true, specifies that associations are to be included in the physical graph projection.

Finally, two additional classes are defined as a means of providing explicitly modeled pattern definitions; that is, pattern definitions composed of MOF metaclass instances (or, MOF metaobjects), rather than the use of logical metamodel class names. These classes consist of *ModeledSemanticContext* and *ModeledGraphSubset*.

ModeledSemanticContext is a subclass of SemanticContext that adds references to instances of MOF:ModelElement and MOF:Association, as well as an association to MOF:ModelElement as a means of specifying anchor classes. Constraints may be specified within ModeledSemanticContext via the inherited SemanticContext::constraint attribute.

ModeledGraphSubset is a subclass of GraphSubset that adds a reference to a single instance of MOF:ModelElement. Like ModeledSemanticContext, it similarly inherits all of its other useful attributes from its base class.

It is expected that, in general, developers of the CWM Metadata Interchange Patterns models that wish to build their solutions around full MOF implementations and objectrich modeling structures will implement and use ModeledSemanticContext and ModeledGraphSubset. On the other hand, developers who wish to construct lighterweight implementations will simply use the SemanticContext and GraphSubset base classes directly, since these base classes rely on logical name references to CWM metamodel elements, rather than direct physical references to instantiated MOF metaclasses.

2.4 Sample Interchange Patterns

We now present two simple examples of both the specification of a metadata interchange pattern and an instance realizing the pattern. The first example illustrates a projection based on the SemanticContext class, the second illustrates a projection based on the GraphSubset class.

For the first example, note that the various example values provided previously in the description of the SemanticContext class collectively define a simple pattern. The projection of the pattern consists of the subset of the CWM metamodel graph containing the metaclasses Dimension and Attribute, and the inherited ClassifierFeature composition relating them. There must be at least one Attribute on the Dimension and precisely one of these Attributes must have the name "key." And within the pattern as a whole, Dimension serves as the anchor element. Any navigation of an instance of this pattern should always start with some instance of Dimension, rather than with a dimensional attribute. A valid instance (or *realization*) of this simple pattern is illustrated in Figure 2-3.



Figure 2-3 Sample Instance Diagram of a Possible Dimensional Metadata Interchange

Figure 2-4 illustrates a sample metadata pattern expressed using the CWM MIP metamodel, with the pattern projection modeled using the GraphSubset class.

In this example, a user wishes to interchange a specific relational schema. This pattern specifies that all objects owned by the relational schema will be included in the transfer. The pattern also indicates that this is not a deepTransfer. This means that we will not traverse associations of object aggregated by the relational schema.

The second part of the pattern states that the type system used by the relational schema must accompany the transfer. Notice that the aggregationsOnly attribute is false. This is because in many cases, by identifying the name of the type system a user could make sense of the transfer.



Figure 2-4 Sample Instance Diagram of a Possible Relational Metadata Interchange

2.5 Conformance Points

An implementation of CWM MIP must minimally provide the InterchangePattern class of Figure 2-1, and the following classes of Figure 2-2: PatternConstraint, Restriction, BindingParameter, Projection, Semantic Context, and GraphSubset.

This means that implementations of CWM MIP are allowed to interchange pattern models only, without necessarily being required to also support the exchange of related pattern instances.

2.5.1 Optional Conformance Points

An implementation of CWM MIP may optionally provide the UnitOfInterchange class of Figure 2-1, and/or the ModeledSemanticContext and ModeledGraphSubset classes of Figure 2-2.

2.6 Pattern Specification and Cataloging

The CWM MIP specification recommends, but does not prescribe, that users of CWM who take the patterns-based approach to metadata interchange document their patterns according to the following general documentation structure (or template):

Name: The name of the pattern (this is the value of the name attribute of an instance of any UnitOfTransfer that realizes this pattern).

Classification: Identifies the structural classification for the pattern. Possible classifications include (but are not limited to) the following:

• *Macro pattern*: A course-grained pattern that represents an overall organizational framework for interchanged metadata.

- *Domain pattern*: A medium-grained pattern that represents some domain-specific context. In general the notion of providing context in meta data interchange is largely realized by specifying and combining various domain patterns.
- *Micro pattern*: A fine-grained pattern that represents some frequently occurring way of organizing basic metadata structures. Higher-level patterns, such as domain patterns, are generally comprised of many different micro patterns.

Category: Identifies a general category that characterizes the usage of the pattern. Possible categories might include (but are not limited to) the following:

- *Interchange*: Any patterns that generally facilitate interchange (e.g., the CWM MIP Model can be viewed as a meta-pattern for facilitating interchange).
- *Mapping*: Any pattern used for establishing mappings/correspondences between model elements.
- Typing: Any pattern used to further classify model elements in some fashion.
- *Extension*: Any pattern that extends or expands the semantics or structure of model instances.
- *Interpretation*: Any pattern that aids in the interpretation of the semantics of some model instance.
- *Generation*: Any pattern that facilitates the automated generation of an implementation of some form.
- *Structural* or *Constructive*: Any pattern that facilitates the construction of more complex structures from simpler ones.

Intent: Statement of purpose/objective of the pattern.

Motivation: Detailed description of the business requirements driving the pattern. Generally amounts to a description of some common data warehousing / business analysis scenario and it requirements for metadata interchange/interoperability.

Also Known As: Provides any other pattern names that used as synonyms of this pattern name.

Projection: A description of the M2-level subset of the CWM metamodel used to establish a common context for metadata interchange. Note that the Projection class of the CWM MIP model and its various subclasses are used for formally modeling such projections.

Restriction(s): A description of M2-level constraints used to restrict or limit the extent of instances of the projection. Generally, restrictions result in structural boundaries placed on instances. Note that the Constraints attribute of SemanticProjection is used to formally express restrictions.

Parameter(s): A set of formal parameters that are used to realize an instance of a pattern. Generally, parameters specify or constrain values for class variables. Note that the Constraints attribute of SemanticProjection is used to formally express parameters.

Consequences: Any consequence (positive or negative) that users of this pattern need to be aware of.

Related Patterns: Any other existing patterns that might be used closely in conjunction with this pattern to achieve some broader metadata interchange or interoperability goal.

Example: Any sample instance diagrams, programmatic code, or XMI fragments that enable developers to better understand how an instance of this pattern is constructed.

Once again, the above recommendations are just that: Recommendations for documenting patterns and pattern usage. They are not prescribed by this specification. The CWM MIP Model is the only prescriptive aspect of this specification. It is anticipated that some de facto means of communicating useful CWM metadata interchange patterns between members of the CWM user community will eventually evolve over time, much as it has within the software patterns community.

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